

gate lines.

Accordingly, the present invention increases an opening ratio by introducing a structure of the color filter substrate without a black matrix and the TFT array substrate where the pixel electrode is partially overlapped with the data and gate lines.

And, the low-reflective layer 230 works as a black matrix for blocking a light filtered by the color filters not to leak to the direction which is not a window as well as lowers reflexivity of light irradiated on the data and gate lines during light irradiation by covering the data line and the gate electrode.

## EFFECT OF THE INVENTION

Accordingly, the present invention enables to increase an opening ratio by introducing a structure of the color filter substrate without a black matrix and the TFT array substrate where the pixel electrode is partially overlapped with the data and gate lines.

Moreover, the present invention enables to improve the image quality since the low-reflective layer works as a black matrix for blocking a light not to leak as well as reduces greatly reflexivity of light irradiated on the data and gate lines during light irradiation.

## WHAT IS CLAIMED IS:

1. A liquid crystal display, comprising:

a color filter substrate on a first transparent substrate including a color filter filtering light and a common electrode;

a gate line on a second transparent substrate;

a data line crossing with the gate line, the data line insulated from the gate line;

a gate electrode at a cross-section between the gate line and the data line, the gate electrode diverging from and protruding out of the gate line;

a TFT transistor including a source electrode connected to the data line and a drain

electrode separated from and confronting the source electrode;  
a low-reflective layer covering the data line and the gate electrode, the low-reflective layer blocking a light filtered by the color filter not to be leak to the direction which is not a window and reducing reflexivity of the light irradiated on surfaces of the data and gate lines;  
a passivation layer covering the TFT including the low-reflective layer wherein a constant hole exposing a portion of the drain electrode is formed in the passivation layer;  
a TFT array substrate on the passivation layer, the TFT array substrate including a pixel electrode connected to the drain electrode through the contact hole; and  
liquid crystal injected and sealed between the TFT array substrate and the color filter substrate.

2. The liquid crystal display according to claim 1, wherein light reflexivity of the low-reflective layer is under 3%.
3. The liquid crystal display according to claim 1, wherein the low-reflective layer is formed of CrOx.
4. The liquid crystal display according to claim 1, wherein the pixel electrode is partially overlapped with the data line and the gate line.